

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

1. (Currently Amended) An organic electroluminescent (EL) display, comprising:
a plurality of ITO films and wirings which are disposed on a ~~transparent substrate via an~~ inter-layer insulating film;
a first insulating film which is disposed between adjacent ones of said ITO films;
an organic EL thin film deposited on said ITO films; and
a cathode thin film deposited on said ITO films; wherein:
the first insulating film comprises a plurality of thickened portions forming insulative mask supporting layers thickened portions preventing a metal mask, which is used in formation of said organic EL thin film and said cathode thin film, from being in contact with a pixel portion of said transparent substrate.

2. (Original) The organic EL display according to claim 1, wherein said display uses a TFT substrate in which said ITO films and TFT layers that are disposed via said interlayer insulating film are connected to one another in an active matrix system.

3. (Previously Presented) The organic EL display according to claim 19, wherein said mask supporting layers are formed by one of a resist, ceramics and an organic resin.

4. through 6. (Cancelled)

7. (Currently Amended): An organic electroluminescent (EL) display, comprising:
a plurality of ITO films which are disposed on a transparent substrate via an inter-layer insulating film;

a first insulating film which is disposed between adjacent ones of said ITO films;

an organic EL thin film deposited on said ITO films;

a cathode thin film deposited on said ITO films; and

a plurality of insulative mask supporting layers that protrude in a reverse tapered shape from the insulating film, and are disposed in a stripe pattern,

said insulative mask supporting layers preventing a metal mask which is used in formation of said organic EL thin film and said cathode thin film, from being in contact with a pixel portion of said transparent substrate.

8. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers are formed from said first insulating film.

9. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers are formed on said first insulating film.

10. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers are stripe-shaped.

11. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers are island-shaped.

12. (Cancelled)

13. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers have a thickness of at least 2 μm .

14. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers have at least one portion which is either taper-shaped or ridge-shaped.

15. (Previously Presented) The organic EL display according to claim 8, wherein said insulative mask supporting layers are constituted by locally thickened portions of said first insulating film.

16. (Previously Presented) The organic EL display according to claim 9, wherein said insulative mask supporting layers are formed directly on said first insulating film.

17. (Previously Presented) The organic EL display according to claim 7, wherein said insulative mask supporting layers are disposed such that a predetermined gap is maintained between a corresponding one of said ITO films and said metal mask.

18. (Previously Presented) The organic EL display according to claim 1, wherein the first insulating film, including the thickened portion, is formed of a single material in a single step.

19. (Previously Presented) The organic EL display according to claim 1, wherein the thickened portions of the first insulating film are formed by mask supporting layers arranged between the first insulating film and the inter-layer insulating film.

20. (Previously Presented) The organic EL display according to claim 19, wherein the first insulating film completely covers the mask supporting layers.

21. (Previously Presented) The organic EL display according to claim 19, wherein said mask supporting layers are stripe-shaped.

22. (Previously Presented) The organic EL display according to claim 19, wherein said mask supporting layers are island-shaped.

23. (Previously Presented) The organic EL display according to claim 19, wherein said mask supporting layers have a thickness of at least 2 μm .

24. (Previously Presented) The organic EL display according to claim 19, wherein said mask supporting layers have at least one portion which is either taper-shaped or ridge-shaped.

25. (Previously Presented) The organic EL display according to claim 19, wherein said mask supporting layers are disposed such that a predetermined gap is maintained between a corresponding one of said ITO films and said metal mask.

26. (New) An organic electroluminescent (EL) display, comprising:
a plurality of ITO films which are disposed on a transparent substrate via an inter-layer insulating film;

a first insulating film which is disposed between adjacent ones of said ITO films;

an organic EL thin film deposited on said ITO films; and

a cathode thin film deposited on said ITO films; wherein:

the first insulating film comprises a plurality of thickened portions forming insulative mask supporting layers thickened portions preventing a metal mask, which is used in formation of said organic EL thin film and said cathode thin film, from being in contact with a pixel portion of said transparent substrate;

the thickened portions of the first insulating film are formed by mask supporting layers arranged between the first insulating film and the inter-layer insulating film; and

the first insulating film completely covers the mask supporting layers.